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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/690,580		10/17/2000	Vladislav Vashchenko	NSC1-H1500	3449
33402	7590	05/21/2003			
		MARK C. PICKE	EXAMINER		
P.O. BOX 300 PETALUMA, CA 94953				FARAHANI, DANA	
				ART UNIT	PAPER NUMBER
				2814	

DATE MAILED: 05/21/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.  09/690,580  Examiner  Dana Farahani ears on the cover sheet with the o	Applicant(s)  VASHCHENKO ET AL.  Art Unit 2814
	Examiner  Dana Farahani  Pars on the cover sheet with the o	Art Unit
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The MAN INC DATE of the	ars on the cover sheet with the o	2814
** THE MAILING DATE OF THIS COMMUNICATION AND		
Period for Reply	IC CET TO EVEIDE	correspondence address
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply well if NO period for reply is specified above, the maximum statutory period will.  - Failure to reply within the set or extended period for reply will, by statute, call and the period part of the mailing days are period will.  - Any reply received by the Office later than three months after the mailing days are period patent term adjustment. See 37 CFR 1.704(b).	vithin the statutory minimum of thirty (30) day apply and will expire SIX (6) MONTHS from	nely filed  s will be considered timely. the mailing date of this communication.
1) Responsive to communication(s) filed on 18 Fe	bruary 2003 .	
• \nabla =	action is non-final.	
3) Since this application is in condition for allowand	ce except for formal matters or	osecution as to the merits is
closed in accordance with the practice under Ex	x parte Quayle, 1935 C.D. 11, 4	53 O.G. 213.
Disposition of Claims		
4) Claim(s) 10-17 and 20-32 is/are pending in the a	application.	
4a) Of the above claim(s) is/are withdrawn	from consideration.	
5) Claim(s) <u>10-17, 20-24, and 28-32</u> is/are allowed.		
6)⊠ Claim(s) <u>25-27</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restriction and/or e	election requirement.	
Application Papers		
9) ☐ The specification is objected to by the Examiner.		
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted	d or b)☐ objected to by the Exan	niner.
Applicant may not request that any objection to the di		
11) The proposed drawing correction filed on is	:: a) ☐ approved b) ☐ disapprov	ved by the Examiner.
If approved, corrected drawings are required in reply		•
12) The oath or declaration is objected to by the Exam	niner.	
riority under 35 U.S.C. §§ 119 and 120		
13) Acknowledgment is made of a claim for foreign pr	riority under 35 U.S.C. § 119(a)	-(d) or (f).
a) ☐ All b) ☐ Some * c) ☐ None of:	,	
1. Certified copies of the priority documents ha	ave been received.	
2. Certified copies of the priority documents ha		n No.
<ul> <li>3. Copies of the certified copies of the priority application from the International Burea</li> <li>* See the attached detailed Office action for a list of t</li> </ul>	documents have been received (PCT Rule 17 2(a))	d in this National Stage
14) Acknowledgment is made of a claim for domestic pr		
<ul> <li>a)  The translation of the foreign language provisi</li> <li>15) Acknowledgment is made of a claim for domestic properties.</li> </ul>	riority under 35 U.S.C. 88 120 a	ivea. and/or 121
ttachment(s)	20 0.0.0. 33 120 6	ATMINITE I
Notice of References Cited (PTO-892)  Notice of Draftsperson's Patent Drawing Review (PTO-948)  Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informal Pa	PTO-413) Paper No(s) ttent Application (PTO-152)
Patent and Trademark Office D-326 (Rev. 04-01) Office Action	Summary	Part of Paper No. 15

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### **DETAILED ACTION**

## Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 25 and 26 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Admitted Prior Art (AAPA) in view of Racanelli (U.S. Patent 6,534,372).

AAPA discloses in figure 1 a collector layer 14, base layer 16, emitter 18, dielectric layer 32, an emitter contact 28, and a base contact 24.

AAPA does not disclose the width of the top surface of the emitter contact is greater than that of the emitter.

Racanelli discloses in figure 1 emitter contact 130 has a wider upper portion.

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to make the emitter contact of AAPA with a wider upper portion to adjust the resistance of the contact (see column 1, lines 53 and 54).

3. Claim 27 is rejected under 35 U.S.C. 103(a) as being unpatentable over AAPA in view of Racanelli as applied to claim 25 above, and further in view of Shakuda (U.S. Patent 6,376,866).

AAPA in view of Racanelli discloses the limitations in the claim, as discussed above, except for the base extender 226, which is polysilicon, having a different material than the first semiconductor material.

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Shakuda discloses that a single silicon substrate is inexpensive and advantageous in devoice manufacturing. Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to make the device of AAPA in a single crystal body, since it would have been cheaper and easier to produce.

## Allowable Subject Matter

- 4. Claims 10-17, 20-24, and 28-32 are allowed.
- 5. The following is a statement of reasons for the indication of allowable subject matter:

The primary reason for the indication of the allowability of claims 14-17, 20-24 and 28-32 is the inclusion therein, in combination as currently claimed, of the limitation of the heat sink contact formed through the dielectric layer; contacting the top surface of the base region. This limitation is found in claims 14-17 and 20-24, and neither disclosed nor thought by the prior art of record, alone or in combination.

The primary reason for the indication of the allowability of claims 10-13 is applicant's argument that AAPA does not disclose an emitter contact wider than the emitter, and a base contact thinner than the emitter contact.

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dana Farahani whose telephone number is (703)305-1914. The examiner can normally be reached on M-F 9:00AM - 6:00PM.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (703)308-4918. The fax phone numbers for the organization where this application or proceeding is assigned are (703)308-7722 for regular communications and (703)308-3432 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0956.

Dana Farahani May 8, 2003

> LONG PHAM PRIMARY EXAMINER